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Curing kinetics and morphology of a nanovesicular epoxy/stearyl-block-poly(ethylene oxide) surfactant system

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Brittle epoxy based thermosets can be made tougher by introducing structural inhomogeneities at the micro- or nanoscale. In that respect, nano vesicles and worm-like micelles from self-assembling block copolymers have been shown to be very effective. This paper describes the curing kinetics and morphology of an epoxy composed of diglycidyl ether of bisphenol A (DGEBA) and 4,4'-methylenedianiline (MDA), modified by 20% of the surfactant stearyl-block-poly(ethylene oxide). Time resolved, synchrotron small-angle X-ray scattering demonstrates that at any time during the epoxy curing process, the surfactant predominantly adopts a bilayer vesicular nano-morphology. Transmission electron microscopy on fully cured systems reveals the coexistence of spherical and worm-like micelles. Differential scanning calorimetry experiments prove that the presence of surfactant reduces the epoxy curing rate but that ultimately full curing is accomplished. The material glass transition temperature falls below that of the pure resin due to plasticization. It is suggested that favorable secondary interactions between the PEO segments and the epoxy resin are responsible for the observed phenomena.

1. Introduction

The development of high performance materials, combining high stiffness and toughness, is one of the main challenges in polymer material science. Toughening stiff, but inherently brittle epoxy based thermosets can be accomplished by introducing structural inhomogeneities at the micro- or nanoscale. However, traditional toughening routes, involving the addition of μm sized rubbery inclusions, often undermine the material stiffness and creep resistance and frequently lower the glass-transition temperature. Alternatively, the blending with high performance thermoplastics creates processing difficulties, while only marginally enhancing the material toughness. Without these shortcomings can be accomplished by amphiphilic block copolymer modification, thereby providing the system with a distinct nanometer morphology, which depends on the nature of the block copolymer, the curing kinetics and matrix viscosity. Dean et al demonstrated that block copolymer vesicles and especially cylindrical (worm-like) micelles can very effectively toughen epoxy resins. This conclusion was challenged in later research but the ultimate conclusion seems to be that indeed morphologies composed of vesicles and cylindrical micelles are optimal for epoxy toughening. The interplay of several parameters dictates the block copolymer self-assembly, which in the end is governed by a minimization of unfavorable interactions. These parameters include the block copolymer molar mass, the (mass or volume) fraction f of each block and the effective interaction energy (ε) between block monomers.

According to Israelachvili, the packing parameter, p, dictates the most likely self-assembled morphology and is defined as follows:

\[ p = \frac{v}{a_0 l_c} \]  

With v the volume of the ‘resinophobic’ chains, a0 the equilibrium area of the ‘resinophilic’ head at the aggregate interface and l the length of the resinophobic tail. Generally, spherical micelles are favored when \( p \leq \frac{1}{3} \), cylindrical micelles when \( \frac{1}{3} \leq p \leq \frac{1}{2} \) and vesicles when \( \frac{1}{2} \leq p \leq 1 \). When an epoxy resin is curing, the miscibility of the resinophilic head with the matrix may decrease, by which the resinophilic moity collapses, the parameter a0 decreases and p increases. This implies that during the course of curing, the self-assembled morphology may change from micelles to vesicles. At a too high incompatibility, macrophase separation may even occur. This happens when an unfavorable mixing enthalpy is combined with the curing-induced decreasing mixing entropy. Only favorable specific intermolecular interactions (e.g. hydrogen bonding) between the epoxy resin and at least one of the blocks can prevent macroscopic phase separation.
Ideally, the nano-morphology is present in the unreacted state and is frozen in by subsequent epoxy network formation and vitrification.  
From an application point of view, the curing kinetics and the final curing degree (conversion) are crucial, besides the materials ultimate properties. During curing the system glass transition temperature ($T_g$) increases. In isothermal conditions, the reaction is chemically controlled until $T_g$ reaches the curing temperature ($T_{cure}$), after which it becomes diffusion controlled. In the latter stage, the reaction can only slowly proceed until $T_g$ is generally 50°C above $T_{cure}$. If the reaction temperature is chosen too low, the final conversion is lower than unity and can only be increased when the temperature is increased.

The present paper reports on the isothermal cure kinetics and nanostructure of a block copolymer modified epoxy. The block copolymer is a stearyl-\textit{block}–poly(ethylene oxide) surfactant of which the PEO chains are expected to mix with the epoxy resin up to very high conversion degrees, whereas stearyl represents the incompatible block. Both blocks are crystallizable. The copolymer is blended with a thermosetting epoxy system composed of diglycidyl ether of bisphenol A (DGEBA) and 4,4’-methylenedianiline (MDA) at the stoichiometric ratio. The ultimate glass transition temperature ($T_g$) of this resin has been reported to be in between 165°C\textsuperscript{22} and 175°C\textsuperscript{23} implying that complete curing of the pure resin is expected after sufficient time at an isothermal temperature of at least 115-125°C.

The isothermal cure kinetics were analyzed by Differential Scanning Calorimetry (DSC) and the morphology by simultaneous synchrotron small and wide angle X-ray scattering (SAXS and WAXD) in combination with Transmission Electron Microscopy (TEM).

2. Experimental

2.1 Materials and sample preparation

Diglycidyl ether of bisphenol A (DGEBA) with epoxide equivalent weight of 184-190 (Epikote 828 LVEL) was purchased at Hexion. The curing agent, 4,4’-methylenedianiline (MDA), was supplied by Aldrich Chemical Co. The structure forming diblock copolymer, namely stearyl-\textit{block}-poly(ethylene oxide)$_{20}$ was supplied under the commercial name Brij S-20 from Aldrich Chemical Co. The blend contains 20% S-20 relative to the total material mass. For its preparation DGEBA was mixed with the right amount of S-20 at 70°C and degassed at 70°C in vacuum. Next, this mixture was brought to 100°C and sonicated for 4 min. Half way the sonication time, the curing agent was added at the stoichiometric ratio (i.e. half the DGEBA molar quantity) while sonication continued. Finally, the mixture was quenched in salted ice water to prevent further curing and stored in a freezer at -18°C until measurements took place. A reference resin was prepared without the addition of S-20, following exactly the same procedure. Figure 1 illustrates the chemical components used in this work.

Figure 1: The epoxy resin is composed of a) diglycidyl ether of bisphenol A (DGEBA) and b) 4,4’-methylenedianiline (MDA). In this study, it is blended with 20% of c) stearyl-block-poly(ethylene oxide)$_{20}$ block copolymer (S-20)

2.2 DSC

The calorimetric measurements were carried out on a TA instruments Q2000 DSC, equipped with an RCS cooler. Nitrogen was used as purge gas. For enthalpy and temperature calibration an indium standard was used. Samples between 12 and 25 mg were enclosed in Tzero aluminum hermetic pans. Firstly, samples were heated from -50 to 300°C at a heating rate of 10°C/min to determine the total reaction enthalpy ($\Delta H_0$). Secondly, isothermal curing was executed at different temperatures while the evolution of the reaction enthalpy was followed. For these isothermal measurements, the samples were heated at 200°C/min to the selected temperature to minimize curing during heating. The isothermal time at a given temperature varied between 300 and 400 min, which was enough to complete the reaction for most samples. After the isothermal curing, samples were cooled at 10°C/min to -50°C and after 2 min heated again to 300°C to record the system glass transition temperature and residual reaction heat.

Another DSC experiment aimed at mimicking the synchrotron X-ray thermal protocol and involved cooling of the starting mixture from 60°C to -50°C at 10°C/min (cooling 1), followed by 2 min isothermal time and heating at the same rate to 130°C (heating 1) where the sample was allowed to cure for 60 min. Afterwards the sample was cooled down to -50°C (cooling 2) and heated up again after 2 min to 200°C (heating 2), all at 10°C/min.

2.3 Synchrotron SAXS/WAXD

Temperature-resolved synchrotron X-ray scattering experiments were performed at DUBBLE, the Dutch-Belgian Beamline (BM26) at the European Synchrotron Radiation Facility (ESRF; Grenoble, France) using a wavelength, $\lambda$, of 1.03 Å. The samples were placed in Tzero Aluminium Hermetic DSC pans. Temperature was imposed through a Linkam DSC 600 heating/freezing stage. Small-angle X-ray scattering (SAXS) patterns were collected on a two-dimensional (2D) Pilatus 1M detector, placed at 2 m from the sample after an evacuated tube. The wide-angle X-ray diffraction (WAXD) data were collected on a Pilatus 300K-W detector from Dectris put closely to the sample. The scattering angles were calibrated with Silver Behenate (SAXS) and HDPE (WAXD). SAXS data were normalized by the total WAXD intensity, assuming conservation of the total scattering mass. The 2D data were averaged azimuthally using the Conex$^{24}$ software and represented as a function of the scattering vector modulus.


q = 4π/λ sin(θ/2), with λ the wavelength and θ the scattering angle. The following temperature profile was imposed to the sample shortly after having been taken out from the freezer: cooling from 60°C to -50°C at 10°C/min (cooling 1), 2 min isothermal time, heating at 10°C/min to 130°C (heating 1), 60 min isothermal at 130°C and cooling from 130°C down to -50°C at 10°C/min (cooling 2). Simultaneous SAXS and WAXD patterns were collected for 4.6 s every 6 s during the segments 1 and 3 and every 60 s during the isothermal segment 2.

### 2.4 TEM

An epoxy-copolymer blend sample was prepared for Transmission Electron Microscopy (TEM) by isothermal curing at 130 °C for 60 min and cooling down at 10 °C/min to room temperature. TEM was performed using a Tecnai 20 microscope, operated at 200 kV. The samples were trimmed using a Diatome trimming tool and subsequently ultrathin sections (70 nm) were obtained at -85°C using a Leica Ultracut S/FCS microtome, equipped with a Diatome 35° diamond knife. The sections were put on a 200 mesh copper grid with a carbon support layer. Staining was applied using the vapor of a rutheniumtetroxide (RuO$_4$)-solution prepared according to Montezinos et al. for 15/30 minutes.

In a second experiment, samples were cured at 45 °C for 2 days and postcured successively at 80 °C for 6 h and 150°C for 90 min. TEM images were made with a Philips CM10, operating at 80 kV. After trimming, 90 nm sections were made using a Drukker International diamond knife at a sample temperature of -80 °C and with the knife at -60 °C. The sections were collected in a solution of water / dimethylsulfoxide (50/50) filled boat, attached to the diamond knife. They were deposited on 300 mesh copper grids and dried on a filter paper. Staining with vapors of a 0.5 wt% aqueous solution of RuO$_4$ was applied for 15-30 min, following the process described elsewhere.

RuO$_4$ selectively stains the components in the order PEO > stearyl ether > cured epoxy, leading to an increased contrast between the potential phases. Note that RuO$_4$ is a powerful oxidizer, irritant to both the eyes and respiratory system. It has to be used with a maximum of safety conditions.

### 3. Results and discussion

#### 3.1 Curing Kinetics of S-20 modified epoxy resin

As curing kinetics are important in epoxy systems, governing the mobility of the matrix and therefore possibly influencing the morphology development, a thorough analysis of the curing kinetics was performed. Figure 2 displays the heat flow as measured by DSC while heating from -90°C to 300 °C at 10 °C/min. The reference resin sample (i.e. without S-20) curing reaction generates a broad exothermic peak, starting at around 80°C and peaking at 164 °C. The total reaction enthalpy (ΔH$_{0}$), calculated by integrating the area enclosed between the curves and straight baselines, amounts to 432.0 J/g for the reference resin and to 358.0 J/g for the blend with 20% S-20. Since the curing starts at 80 °C, it is clear that the preparation method, involving sonication at 100 °C should already have induced some curing. To estimate the conversions properly, one must determine the maximum total reaction enthalpy, further referred to as ΔH$_{max}$. A resin with stoichiometric amounts of DGEBA and MDA was prepared by stirring rather than sonicating at 100 °C for only 1 min in order to minimize curing during preparation. This system was subjected to a similar DSC heating run, yielding a ΔH$_{max}$ of 447.8 J/g. These conditions cannot fully exclude resin curing but are mandatory to enable MDA melting (the melting point is 89°C) and resin mixing.

The curing enthalpy during sample preparation (ΔH$_{prep} \) can be calculated for both the S-20 modified and unmodified resins through equation 2:

$$ΔH_{prep} = ΔH_{max} - ΔH_0$$  \hspace{1cm} (2)

For the unmodified resin $ΔH_{prep,0\% S-20}$ is calculated as follows:

$$ΔH_{prep,0\% S-20} = ΔH_{max} - ΔH_0$$  \hspace{1cm} (3)

For the reference resin, it appears that (15.8/447.8)*100 = 3.5% cured during the standard sample preparation method, involving sonication. For the resin modified with 20% S-20, the measured reaction enthalpy is 358.0 J/g. The curing enthalpy during sample preparation for this material (ΔH$_{prep,20\% S-20}$), which contains 80% epoxy equals:

$$ΔH_{prep,20\% S-20} = (ΔH_{max} + 0.8) - ΔH_0$$  \hspace{1cm} (4)

$$= 447.8 \cdot g^{-1} + 0.8 - 358.0 \cdot g^{-1} = 0.2 \cdot g^{-1}$$

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One can readily compute that only $0.2/(447.8*0.8)*100 = 0.05\%$ of the resin cured during blend preparation. The decreased conversion during mixing compared to the reference resin indicates that blending with S-20 reduces the reaction rate at $100\, ^\circ\text{C}$. Figure 2 reveals that the reaction kinetics in general is slowed down: the peak maximum is shifted to a higher temperature compared to pure resin. Ultimately, during heating at $10\, ^\circ\text{C}/\text{min}$ the S-20 modified system reaches full curing once $280\, ^\circ\text{C}$ has been exceeded. It should be mentioned though that pure S-20 starts decomposing at about $150\, ^\circ\text{C}$ following thermogravimetric evidence (data not shown). This degradation of S-20 as well as the heat associated with it (expected to be $5.5\, \text{J/g}$ in the blend) was neglected in the $\Delta H_{\text{prep,20\% S-20}}$ determination, but sets an upper limit to the useful isothermal curing temperature, which was limited to $130\, ^\circ\text{C}$ in the present study.

Figure 3 displays the heat flow generated during isothermal conditions after heating the pure (top) and S-20 modified (bottom) resins to the desired temperature at $200\, ^\circ\text{C}/\text{min}$. As heat flow is proportional to the reaction rate, the presence of an (isothermal) exothermic peak points at an acceleration of the initial reaction rate. This is known to be due to the formation of hydroxyl groups during the epoxy-amino reaction, which induce an autocatalytic effect. After this maximum, the reaction rate decreases, which may be due to a decrease of available functional groups, exhaustion of more reactive primary amines, gelation or vitrification. For both systems the maximum reaction rate is higher and the time to reach the maximum decreases at increasing isothermal temperatures. Reactions are thus accelerated by a thermal effect.

The epoxy resin conversion ($\alpha$) at time t is calculated by dividing the reaction enthalpy at time t by the maximum total reaction enthalpy

$$\alpha = \frac{\Delta H_t}{\Delta H_{\text{max}}}$$

(5)

Taking the reaction enthalpy during preparation ($\Delta H_{\text{prep}}$) into account, equation 5 alters into:

$$\alpha = \frac{\Delta H_t + \Delta H_{\text{prep,20\% S-20}}}{\Delta H_{\text{max}}}$$

(6)

for the reference resin. For the S-20 modified system equation 5 becomes:

$$\alpha = \frac{\Delta H_t + \Delta H_{\text{prep,20\% S-20}}}{\Delta H_{\text{max}} + 0.8}$$

(7)

Obviously, the conversion-time plots in Figure 4 equally reveal the faster conversion rate with increasing isothermal temperature and the slower reaction kinetics for S-20 modified systems. The ultimate conversion degree after $300\, \text{min}$ for the pure resin increases from $82\%$ to $98\%$ in going from curing at $80\, ^\circ\text{C}$ to $120\, ^\circ\text{C}$. At $130\, ^\circ\text{C}$, however, the ultimate conversion (calculated using equation 6) apparently declined to $94\%$ although full curing is expected (data not shown). Given the high curing rate above $120\, ^\circ\text{C}$ (see Figure 2), it seems that $6\%$ conversion took place during the heating ramp to $130\, ^\circ\text{C}$. The conversion data in Figure 4 for the pure resin at $130\, ^\circ\text{C}$ are therefore shifted to reach an ultimate conversion of 1 at $300\, \text{min}$. This experimental problem does not exist for the S-20 modified systems. However, another complication exists for this material for curing at $90\, ^\circ\text{C}$ and $80\, ^\circ\text{C}$ since even after $400\, \text{min}$ no stable DSC baseline was reached, indicating that the reaction was not fully over yet. The conversion data in Figure 4 for these temperatures are thus only indicative and based on using the heat flow value at $400\, \text{min}$ as integration baseline. The experiments at these temperatures were excluded for further analysis. The DSC heating runs of pure epoxy resin after cooling from $T_{\text{cure}}$ displayed in Figure 5 reveal an enthalpy recovery peak about $25\, ^\circ\text{C}$ above the respective $T_{\text{cure}}$ indicating that all samples vitrified and relaxed during curing and reached the (very) slow diffusion controlled stage of curing. All heating runs, except the one after curing at $130\, ^\circ\text{C}$, contain a significant exothermic peak right after devitrification due to residual curing. The residual heat is larger the lower $T_{\text{cure}}$. Conform the mentioned isothermal curing completeness, no residual exothermic heat was observed during heating the S-20 modified resins, irrespective of the curing temperature. For the $80\, ^\circ\text{C}$ experiment some residual heat was expected (cfr. supra), but
it most likely escaped the observation due to being very small and smeared out over a broad temperature range. Most interestingly, a constant devitrification temperature was observed at about 60 °C, which is far below \( T_{\infty} \) of this pure resin (165-175 °C).

Complete curing in combination with a \( T_{\infty} \) reduction, suggests that S-20 acts as a plasticizer for the epoxy resin. Whether or not S-20 interferes chemically can be deduced from an analysis of the curing reaction activation energy as outlined in the next paragraph.

Following arguments by Lu and Kim,\textsuperscript{22} the time to reach a given conversion, \( t_\alpha \), is related to the reaction activation energy, \( E_a \), and the thermodynamic temperature, \( T \), via:

\[
\ln t_\alpha = \frac{E_a}{RT} + A
\]  

with \( R \) being the gas constant (8.31 JK\(^{-1}\)mol\(^{-1}\)) and \( A \) a constant, depending on the pre-exponential factor of the Arrhenius equation and a function describing how the conversion rate depends on the concentration of the reacting species. If the reaction mechanism is temperature independent, plotting \( \ln t_\alpha \) for different curing temperatures (expressed as 1/\( T \)) should yield straight lines with a slope equal to \( E_a/R \). Changes in \( E_a \) as a function of the conversion may point to changes in the curing mechanism.

Figure 6 is such a graph for the pure epoxy resin. All lines are linear. Conversions above 70% (data not shown) produced non-linear graphs, likely because a diffusion controlled stage was entered at the lowest curing temperatures.\textsuperscript{28} The experiment at 130 °C was excluded because of the uncertainty in the conversion.

In Figure 7, \( E_a \) extracted from the slopes in Figure 6 is displayed (open circles) for the different conversions. These values are slightly higher compared to values reported earlier for the same resin.\textsuperscript{22} The decrease in \( E_a \) with increasing conversion has been observed earlier and has been attributed to the formation of hydroxyl groups from the reaction between the amine and the epoxy.\textsuperscript{29} The hydroxyl groups facilitate epoxy ring opening and thereby catalyze the curing reaction. This is accompanied by a reduction of the activation energy.\textsuperscript{29} At higher conversions, one expects and often observes an increase in \( E_a \) because of an increase of the viscosity of the reaction mixture.\textsuperscript{29} But, as mentioned above, these data were excluded because of the non-linearity in the related graphs.

A change in the reaction mechanism by adding S-20, would show up in a change of \( E_a \) compared to in the pure epoxy resin. In Figure 8, the counterpart of Figure 6 is shown for the S-20 modified epoxy resin.
modified epoxy resin and the corresponding $E_a$ values are included in Figure 7 (black squares). Here the 130 °C data are included but the 80 °C and 90 °C data are left out for reasons mentioned above. The $E_a$ values are not different from the pure resin values, except at the highest temperatures where the pure resin values are slightly higher. This result suggests that S-20 does not mechanistically interfere in the epoxy curing reaction. A plasticizing effect can be inferred from the lower $E_a$ values for the S-20 modified system at high conversions where the pure epoxy system apparently starts experiencing mobility related problems. The slower curing rate for S-20 modified systems compared to pure epoxy resin can thus be fully attributed to a dilution effect.

3.2 Morphology of S-20 modified epoxy resin

DSC. Figure 9 illustrates the DSC traces related to the thermal characterization of the S-20 modified epoxy resin. In cooling 1 an exothermic signal (grey shaded area) is seen at temperatures just above the step like vitrification signal of the uncured resin at about -25 °C. During subsequent heating 1 an endothermic signal (grey area) is observed right after the devitrification. During further heating, heat is released starting from approximately 80 °C onwards due to the resin curing. This reaction continues isothermally at 130 °C and seems to be finished after 90 min. During subsequent cooling 2, the material vitreifies over a rather broad range of 80°C down to about 30°C and devitrifies again during heating 2 without having past any exo- or endothermic events. Note that in contrast to the pure epoxy resin and irrespective of the isothermal curing temperature, vitrification and devitrification occur in the same ranges (data not shown).

The thermal protocol up to the asterisk in the bottom panel of Figure 9, corresponds to the protocol imposed to the sample that was investigated by TEM.

TEM. Figure 10A represents a typical TEM image, revealing closed loop features, dot-like droplets and linear streaks as well as rounded areas that are shaded grey. These features are due to the PEO topology since RuO$_4$ preferentially stains this component. The loops and areas are associated with vesicles of which the vesicular wall structure will be revealed via the SAXS experiments. The loops represent vesicular walls, running vertically through the entire section and seen edge on, whereas the areas are interpreted as vesicular caps enclosed within the section and seen flat on in projection. The linear, non-closed streaks are associated with long, cylindrical micelles and the dot-like droplets to spherical ones.

WAXD. The material morphology development over the entire thermal program from the uncured to the fully cured state can be derived from the time resolved X-ray measurements. All WAXD patterns are very similar to curve A in Figure 11, exhibiting a broad halo typical of amorphous material. Only at temperatures at and below the exothermic maximum during cooling 1 (gray area in Figure 9) and the subsequent endotherm during heating 1, the patterns include a small narrow reflection, which is shaded black in the -50 °C pattern.
in Figure 11. Comparison with literature suggests that this reflection is due to either orthorhombically or hexagonally packed aliphatic stearyl chains. For a hexagonal structure, one clear reflection at approximately $q = 1.5$ Å is expected, whereas for orthorhombic material besides the strongest 110 reflection at about $q = 1.5$ Å also a weaker 200 reflection at $q = 1.62$ Å is expected. The absence of the latter reflection might be just a consequence of sensitivity with the amount of crystalline material being very small. The evolution of the area of this crystalline reflection is depicted as a function of time in the bottom panel of Figure 12. This area represents a WAXD crystallinity index and was normalized such that its maximum value equals 1. In further calculations, it will be assumed that all stearyl units are crystalline at the lowest temperature. The index thus represents the crystalline stearyl fraction.

**SAXS.** The top panel in Figure 12 displays the followed temperature profile and highlights six temperatures of which the corresponding SAXS patterns, $I(q)$, are shown in Figure 13. The total scattering power or the ‘invariant’ at a given time, $Q_t$, for all SAXS patterns was calculated as:

$$Q_t = \int_{q_{min}}^{q_{max}} [I(q) - B] 4\pi q^2 dq$$

(9)

$B$ is a constant background due to density fluctuations and equals the average scattered intensity in the range $0.33 \text{ Å}^{-1} < q < 0.35 \text{ Å}^{-1}$. The background values are represented by the horizontal full lines in Figure 13. The SAXS invariant and background are depicted using arbitrary units in Figure 12 since measurements were not conducted on an absolute scale. $Q_t$ was nevertheless interpreted in terms of (micro)phase density evolutions, relying on a scaling procedure and some assumptions. Given that the stearyl moieties dislike the epoxy resin, most realistically the vesicular walls and micelles should be composed of a central stearyl microphase (with electron density $\rho_1$), followed by a PEO layer on both sides (with electron density $\rho_2$). With the epoxy matrix, the minimum number of electron densities to account for in the interpretation of $Q_t$ is three.

The mass density of the amorphous (liquid like) stearyl aliphatic chains, $d_{amo}$, resembles that of molten polyethylene, which can be approximated by:

$$d_{amo} = 0.8674 - 6.313 \times 10^{-4} T + 3.67 \times 10^{-7} T^2 - 5.5 \times 10^{-10} T^3 \left[ \frac{mole \text{ electrons}}{cm^3} \right]$$

(10)

The density of orthorhombic crystalline material, $d_{cryst}$, can be computed from:

$$d_{cryst} = \frac{1}{0.9044 \times 10^{-4} T + 4.63 \times 10^{-4} T^2} \left[ \frac{mole \text{ electrons}}{cm^3} \right]$$

(11)

In both equations 10 and 11, $T$ is the temperature in °C. Multiplying these mass densities with 0.57 mole electrons/g yields the electron density [mole electrons/cm³] as function of temperature as depicted in Figure 14 over the entire thermal protocol.

The density of amorphous PEO at 25 °C equals 1.092 g/cm³, which after multiplying with 0.5448 mole electrons/g yields an electron density of 0.59 mole electrons/cm³. DGEBA has a mass density of 1.17 g/cm³ at room temperature and MDA a (liquid) density of 1.05 g/cm³ at 100 °C. Assuming additivity and neglecting the MDA liquid density difference between 100 °C and 25 °C, the density of a stoichiometric mixture is 1.14 g/cm³. Multiplying with 0.535 mole electrons/g yields the electron density of uncured resin at 25 °C, i.e. 0.61 mole electrons/cm³. This value is very similar to that of amorphous PEO but rather different from that of the (amorphous) aliphatic segments at point A or C (see Figure 14). With PEO and epoxy resin being well mixed, it can be assumed that $Q_t$ is dominated by the contrast between the central...
stearyl layer and the rest (PEO plus epoxy), further referred to as the matrix with electron density, $\rho_m$.

Accordingly, one can write for the invariant at a given time, $t$, and irrespective of the actual morphology, the following expression:

$$Q_t = P(\rho_{m,t} - \rho_{1,t})^2$$  \hspace{1cm} (12)

with $P$ a proportionality factor. $P$ should remain constant as long as the volume fraction of microphase separated stearyl units remains constant and $Q_t$ should only differ from e.g. the invariant at point C, $Q_C$, because of a change in electron density difference between that of the stearyl phase, $\rho_{1,t}$, and the matrix $\rho_{m,t}$. Under these conditions and with knowledge of $\rho_{m,C}$, $\rho_{1,C}$, and $\rho_{1,t}$ one can calculate $\rho_{m,t}$ at any time:

$$\rho_{m,t} = \sqrt[\frac{Q_t}{P}]{(\rho_{m,C} - \rho_{1,C})^2 + \rho_{1,t}}$$  \hspace{1cm} (13)

Values for $\rho_{m,t}$ at times larger than point C, are presented in Figure 14 using full squares. For $\rho_{m,C}$, 0.61 mole electrons/cm$^3$ was used. For $\rho_{1,C}$ and $\rho_{1,t}$ the density of liquid aliphatic chains (equation 10) was multiplied by 0.57 mole electrons/g. Point C thus represents the reference for these calculations.

At times shorter than point C, part of the stearyl phases is in the crystalline state. To find $\rho_{m,t}$ the following quadratic equation needs to be solved, assuming that the stearyl microphases scatter independently and are either fully crystalline or fully amorphous:

$$\sqrt[\frac{Q_t}{P}]{(\rho_{m,C} - \rho_{1,C})^2} = \beta(\rho_{m,t} - \rho_{1,\text{cryst}})^2 + (1-\beta)(\rho_{m,t} - \rho_{1,\text{amo}})^2$$  \hspace{1cm} (14)

$\beta$ is the fraction of crystallized stearyl phases. For $\beta$ the WAXD crystallinity index in Figure 12 was used. The parameters $\rho_{1,\text{amo}}$ and $\rho_{1,\text{cryst}}$ were derived from the equations 10 and 11 and multiplication by 0.57 mole electrons/g. The result for $\rho_{m,t}$ is added to Figure 14 using open squares. The evolution of $\rho_{m,t}$ is thus based on the assumption that changes in $Q_t$ are solely due to contrast changes. This hypothesis only makes sense if the resulting $\rho_{m,t}$ evolution is meaningful. This seems to be the case, as is discussed next.

To a first approximation, $\rho_{m,t}$ in Figure 14 can be interpreted as being the evolution of the epoxy (electron) density. When cooled down from 25 °C (A) to -50 °C (B), the uncured epoxy density increases due to thermal contraction. The contraction decreases strongly from -22 °C onwards. This temperature coincides with the onset of vitrification seen in Figure 9. During subsequent heating, the material expands and does so more rapidly at temperatures above -23 °C, which is at the end of the devitrification range in Figure 9. The thermal expansion is not linear, in particular when surpassing 70 °C since the contraction due to the epoxy curing starts interfering. Once 130 °C is reached at D, curing progresses isothermally. The density increase at 130 °C is thus fully associated with the curing reaction. During cooling from E to F one expects a thermal contraction. Instead, the density remains rather constant, likely because of rapid vitrification during cooling. Interestingly, the vitrified, cured epoxy density at F is comparable with or even slightly lower than the uncured resin density at C (both 25 °C). This contra-intuitive effect has been reported earlier and can occur when rather fully cured systems vitrify isothermally or during cooling prior to reaching room temperature. Note that the curing induced densification of epoxy resins appears to be rather heterogeneous. This can be deduced from the increase of the SAXS background during curing (Figure 12). In the simplest case, this background is only expected to increase with temperature due to increasing thermal density fluctuations. Curing seems to bring extra fluctuations, which are frozen in by gelation and vitrification because the expected background decrease during cooling from E to F is minimal. The heterogeneous nature of the epoxy resin can also be inferred from the broad glass transition range in the second cooling and heating runs of Figure 9. In the past, attempts have been made to link changes in the SAXS background to the epoxy curing chemistry or to the creation of microvoids. The latter option is excluded since TEM did not provide any evidence for such voids (Figure 10A). In summary, the evolution of the epoxy electron density seems realistic, supporting the underlying assumption that the stearyl demixing remains at all temperatures and times.

**SAXS modellings.** The TEM picture in Figure 10A revealed that the morphology at point F in the thermal program (see Figure 12 top panel) is predominantly vesicular. Accepting that the demixing remains, does not imply that the vesicular morphology dominates at all times and temperatures. Attempts to describe the representative data in Figure 13 in terms of (layered) spherical or cylindrical micelles using earlier described models remained unsuccessful. In contrast, all data could adequately be described as being due to (predominantly) vesicles.

When sufficiently large, the vesicular curvature is limited and the SAXS patterns can be modelled as the scattering from flat vesicular walls. The black lines over the SAXS patterns in Figure 13 are interpretations in terms of such a layer like morphology. However, to accurately describe all features in the SAXS patterns, 4 electron density levels had to be used rather than 3...
and transition zones between them needed to be incorporated. Following Goderis et al., such a 4 level system can be modelled as 3 superimposed block-like entities with electron density $\rho_1$ and block length $l_i$ on top of a constant 4$^{th}$ electron density level. All distances $l_i$ are defined symmetrically around the center of the vesicle wall and the constraint holds that $l_i < l_{i+1}$. Equation 15 describes the corresponding SAXS pattern:

$$I(q) = \frac{C}{4\pi q} F(q)^2 + B$$

with

$$F(q) = \sum_{i=1}^{3} \frac{(\sigma_{i+1} - \sigma_i)}{q} \sin \left( \frac{2\pi l_i}{q} \right) \exp\left(-0.5\sigma_i^2 l_i^2 q^2\right)$$

$\sigma_{i+1}$ characterizes the widths of the transitions zones between the layers i and i+1. The parameters $B$ and $C$ respectively represent the background due to density fluctuations and a constant proportional to the volume occupied by the vesicles and the X-ray flux. The distance between the vesicle walls and/or the stacking disorder is supposed to be large enough not to cause any inter-wall interference in the recorded $q$-range. In a first step, equation 15 was fitted to (the strongest) pattern B in Figure 13. This was done by minimizing the sum of squared differences between the experimental and theoretical (model) curve on a logarithmic scale, while varying the parameters in Equation 15. This action was done using the solver built into Microsoft Excel. $\rho_1$ and $\rho_4$ were set to the crystalline aliphatic density and epoxy matrix density highlighted at the points B in Figure 14. It furthermore turned out that $\sigma_{1,2}$ was close to zero. This parameter was therefore set to zero in a second fitting iteration, without affecting the quality of the fit. This reduced the number of fitting parameters to 9. Via this procedure, a value for C was obtained set equal to the relevant amorphous aliphatic (stearyl) and epoxy matrix densities highlighted in Figure 14 with the letter labels.

Rather than reporting the resulting model parameters of equation 15, it is instructive to compute and discuss the electron density profiles across the vesicular wall. These were obtained via a Fourier cosine transformation of the model scattering amplitude according to:

$$\rho(x) = \frac{1}{2\pi} \int_{0}^{\infty} 2F(q) \cos(qx) \, dq + \rho_4$$

The electron density profiles corresponding to the SAXS patterns of Figure 13 are displayed in Figure 15 together with sketches of the associated layer structure. For all temperatures and times, the central, low electron density layer has a thickness of approximately 15 Å, which is shorter than an all-trans, fully stretched stearyl chain (22 Å), implying that the stearyl chains in the center of the bilayer are interdigitated and tilted (see the blue lines in the sketches of Figure 15). Since the thickness is fairly constant, the density of this layer can only vary by the lateral separation of the aliphatic chains. Changes are related to thermal expansion as well as to crystallization as in situation B.
The uncured epoxy resin is represented with green spheres in Figure 15, thereby neglecting the two component nature of the resin. At point B, all stearyl moieties are assumed to be closely packed in the crystalline state. The epoxy resin is in the uncured, vitrified state and has a higher density than in point A because of thermal contraction (see the magenta electron density profile in Figure 15). The PEO layers now seem to be (electron) denser than the epoxy matrix. It is suggested that – because of the closer aliphatic packing – the PEO congestion now exists over the entire PEO layer, leaving little space for epoxy resin in between them. Upon heating to point C, all crystals melt and a situation identical to as in A is obtained. Upon further heating to point D at 130 °C, all densities further decrease because of thermal expansion. Otherwise, the (black) electron density profile for situation D in Figure 15 is very similar to that of A or C. However, the PEO regions do not stand out so clearly, suggesting less congestion at the interfaces with the stearyl layer and a higher degree of mixing with the epoxy resin compared to in A and C. Less congestion follows from the higher inter-chain distances in the central stearyl layer. At E, the system is fully cured and still at 130 °C. The density of the central stearyl layer is identical to in D. In contrast, the cured epoxy density as well as the density of the PEO layers has increased compared to in D. The former is expected from the curing reaction. The PEO densification is accompanied by a contraction of the PEO layer, assuming that the regions of highest density represent the PEO layers. The thinner layers suggest that the PEO chains collapsed during the curing process, thereby segregating the epoxy. This process follows from the reduced mixing entropy during epoxy curing, as mentioned in the introduction. The stearyl chain tilt and interdigitation in the present case might be controlled by the necessity of accommodating the collapsed PEO chains. However, the dynamic interaction of the soft PEO chains with the curing epoxy at 130 °C may induce its softening (plasticization) and decrease of the glass transition temperature even up to distances relatively far away from the actual interface. With 20% S-20 and vesicles that are approximately 100 Å thick, it can be calculated that (for the hypothetic case of periodically stacked layers) the interaction penetration only needs to be 200 Å to affect the entire material volume. A progressively decaying interaction of the PEO chains with epoxy matrix may contribute to the heterogeneous nature of the epoxy matrix, inferred from the large SAXS background and the broad vitrification range. After cooling down the cured material to 25 °C at point F, an electron density profile is obtained very similar to in A or C. The PEO density beyond the congestion points now reaches that of amorphous PEO, suggesting that it is a rather pure PEO phase. To avoid PEO overcrowding at the interface with the central stearyl layer, part of the PEO chains must have succeeded in stretching out to within the cured epoxy resin prior to its vitrification. The absence of exothermic heat in the DSC cooling run 2 in Figure 9 demonstrates that the central stearyl layer is no longer able to crystallize after epoxy curing. The closer aliphatic chain packing required for crystallization seems to be prevented by the matrix vitrification prior to reaching the supercooling needed for crystallization.

### 3.3 Influence of curing protocol on the morphology of S-20 modified epoxy resin

To check the robustness of the obtained morphology, a second curing protocol was followed at 45 °C for a long time. The full protocol is outlined in section 2.4. This temperature falls below the ultimate Tg of the S-20 modified resin. Using equation 8 and the data obtained in Figure 8, one can estimate that the gelation point (70% conversion was taken) will be reached in less than 6 hours. This ensures that the morphology is fixed. Most likely curing was rather complete after 2 days, making the two post-curing steps at 80 °C and 150 °C pointless. Be that as it may, the morphology after this curing protocol as illustrated in Figure 10B was identical to after curing at 130 °C, proving the morphological robustness of this formulation.

### Conclusions

In this work an epoxy matrix, DGEBA/MDA, was blended with 20% of an amphiphilic diblock copolymer, stearyl-block-poly(ethylene oxide20) and abbreviated as S-20, in order to introduce nanostructures by self-assembly. The epoxy curing kinetics, thermal properties and morphology were studied at the end of the curing protocol by transmission electron microscopy (TEM) and by time resolved X-ray scattering during the entire process. The S-20 modified system cures somewhat slower compared to pure epoxy resin because S-20 dilutes the epoxy reagents. However, irrespective of the studied curing temperature, which was varied between 80 °C and 130 °C, conversion progressed up to unity after curing for a sufficiently long time. S-20 does not interfere mechanistically in the resin curing reaction since the activation energies of the S-20 modified systems are identical to pure epoxy resin, at least in the early conversion stages. At higher conversions the pure resin starts experiencing mobility related problems, which lead to higher activation energies. This effect is absent in the S-20 modified system. S-20 acts as a plasticizer, bringing the cured resin glass transition temperature down from 170 °C for the pure resin to 30-90 °C for the S-20 modified system.

TEM at room temperature revealed that S-20 self-assembles into predominantly vesicles, together with a smaller fraction of cylindrical and spherical micelles. Relying on a modelling of the small angle X-ray scattering (SAXS) patterns, the vesicle walls are bilayers with stearyl moieties in the center and PEO facing the epoxy resin on both sides. Stearyl demixing remains at any time, regardless of its crystallization or the curing stage of the resin. Furthermore, SAXS based electron density profiles across the vesicular wall revealed that the stearyl chains in the central 15 Å thick layer are tilted and interdigitated throughout the entire protocol. At room temperature, the uncured epoxy is present in between the PEO chains which are presumably stretched out. The stearyl densification induced by its
crystallization at low temperatures forces the PEO chains into a closer packing by which the uncured epoxy resin is squeezed out. High temperature curing reduces the PEO compatibility with the resin, by which the PEO chains coil up.

Plasticization of the matrix is an unwanted effect. However, for modifying the epoxy mechanical properties, lower S-20 concentrations can be used. The formation of nanostructures seems to be rather robust when adding S-20 since nanostructures remain during the entire curing cycle and as altering the curing protocol essentially produces the same nanostructures.

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